

INFORMATION DISCLOSURE CITATION
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Applicant(s)
Minh Q. Hoang, et al

Filing Date

Group Art Unit

U.S. PATENT DOCUMENTS

EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
		4,632,772	12/30/86	Garabedian, et al	252	106	2/22/82
		5,439,681	8/8/95	Khan, et al	424	400	6/7/93
		5,837,274	11/17/98	Shick, et al	424	406	10/22/96
		5,955,408	9/21/99	Kaiser, et al	510	131	7/9/97
		6,053,369	4/25/00	Hoang, et al	222	190	9/28/98
		6,308,866 B1	10/30/01	Hoang, et al	222	189.11	2/24/00

FOREIGN PATENT DOCUMENTS

REF	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
						YES	NO
	0 086 878	8/31/83	Europe	C11D	3/00		
	0 689 767 A2	1/3/96	Europe	A01N	31/02		
	0 882 446 A1	12/9/98	Europe	A61K	7/48		
	WO 91/17237	11/14/91	PCT	C11D	17/00		
	WO 96/06153	2/29/96	PCT	C11D	3/00		

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

	BASF Corporation Jordapon ACI 30G (CTFA/INCI: Ammonium Cocoyl Isethionate) July 1999 7 pages
	BASF Corporation Pluronic L64 Block Copolymer Surfactant 2/27/96 6 pages

EXAMINER	DATE CONSIDERED
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REF	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
						YES	NO
	WO 01/74983A1		PCT			✓	

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		PCT Search Report

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